

Atomically of MoS₂ thin layers via a two step thermal evaporation - exfoliation method

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Electronic Supplementary Information

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ESI.1 AFM Images

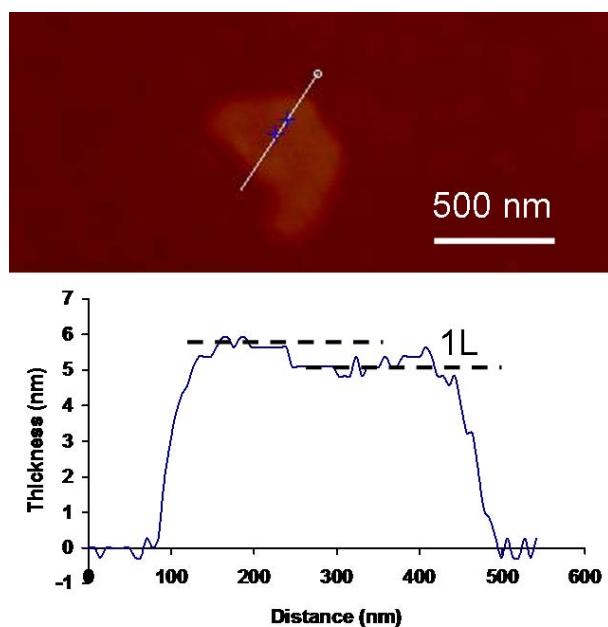


Fig. S1 A flake made of 8 layers. A one layer step on the top of the 8th layer can be resolved.

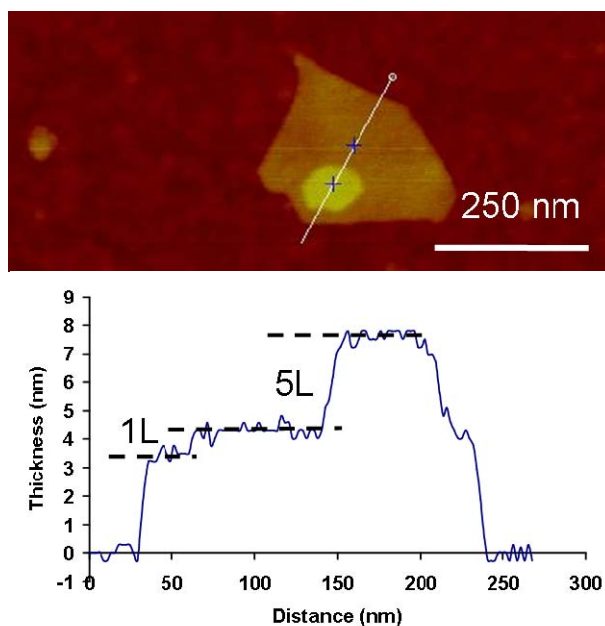
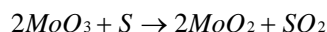


Fig. S2 A flake made of 6 layers. A single step and a 5 layer sheet on the top of this can also be observed

ESI.2 Proposed Reaction Mechanisms

At the lower temperatures of 775 °C, MoO₃ has been reduced to MoO₂ as the evaporated sulphur interacts with oxygen atoms of MoO₃ to produce SO₂, which is extracted as a gaseous by-product. At the higher temperature of 830 °C a mixture of MoS₂ and MoO₃ is obtained as the sulphur replaces the oxygen in MoO₂. This leads to the decrease in the percentage of gaseous sulphur which makes the annealing atmosphere less of a reduction environment. The replaced oxygen ions at higher temperatures along with the lack of sulphur allow a fraction of MoO₂ to re-oxidize back to MoO₃. Similar interactions have been reported by Ressler et al.³⁰ in a study of the formation of sub Mo oxides from MoO₃ in a reducing (H₂) environment. The proposed reaction mechanisms at 830 °C provide an overview of the composition of the end-product in relation to the initial ratio of reactants.

Proposed reaction mechanism at 775 °C:



Proposed reaction mechanism at 830 °C:

